

PROCEEDINGS OF SPIE

Micro-Optics 2010

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Editors

12–16 April 2010
Brussels, Belgium

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Published by
SPIE

Volume 7716

Proceedings of SPIE, 0277-786X, v. 7716

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Please use the following format to cite material from this book:

Author(s), "Title of Paper," in *Micro-Optics 2010*, edited by Hugo Thienpont, Peter Van Daele, Jürgen Mohr, Hans Zappe, Proceedings of SPIE Vol. 7716 (SPIE, Bellingham, WA, 2010) Article CID Number.

ISSN 0277-786X

ISBN 9780819481894

Published by

SPIE

P.O. Box 10, Bellingham, Washington 98227-0010 USA

Telephone +1 360 676 3290 (Pacific Time) · Fax +1 360 647 1445

SPIE.org

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